

China

CMC

COA

Wf6

Tungsten Hexafluoride

Sea Transportation

10L 40L 50L

2812190091

200t/Year

7783-82-6

232-029-1

Industrial Pure Air

Wf6

CMC

China

# Semiconductor Industry Usage High Purity Wf6 Cylinder Gas Tungsten Hexafluoride

#### **Basic Information**

- Place of Origin:
- Brand Name:
- Certification:
- Model Number:

**Our Product Introduction** 

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- Minimum Order Quantity: 1 Piece
- Price: US \$ 15/PC
- Packaging Details: Cylinder/Tank
- Delivery Time: 15 days
- Payment Terms: L/C, T/T
- Supply Ability: 200 Tons/Year

## **Product Specification**

- Product Name: Tungsten Hexafluoride
  Appearance: Colorless
  Purity: 99.999%
  Transport: By Sea
- Model No.:
- Transport Package:
- Specification:
- Trademark:
- Origin:
- HS Code:
- Supply Ability:
- CAS No.:
- Formula:
- EINECS:
- Constituent:



**Tungsten Hexafluoride** 

## More Images



## **Product Description**

Tungsten hexafluoride (WF6) is a compound composed of tungsten and fluorine. It is a colorless, highly reactive, and volatile gas. Here are some key points about tungsten hexafluoride: Chemical Formula: WF6

Molecular Weight: 297.84 g/mol

Appearance: WF6 is a colorless gas at room temperature and pressure.

Odor: It does not have a distinct odor.

Reactivity: Tungsten hexafluoride is highly reactive and can react violently with water and moisture. It hydrolyzes rapidly to form tungstic acid (H2WO4) and hydrogen fluoride (HF).

Toxicity: Like other metal halides, tungsten hexafluoride is toxic and should be handled with caution. It can cause severe irritation to the skin, eyes, and respiratory system upon exposure.

Uses: WF6 is primarily used in the semiconductor industry for the deposition of tungsten metal during the manufacturing of integrated circuits (ICs). It is employed in a chemical vapor deposition (CVD) process to create thin films of tungsten. These films are essential for the production of microprocessors and other electronic components.

Safety precautions: Due to its reactivity and toxicity, proper safety measures should be followed when handling tungsten hexafluoride. It should be stored and used in well-ventilated areas with appropriate personal protective equipment (PPE).

2190091

Overview

Basic Info.			
Model NO.	WF6	Transport Package	Cylinder
Specification	10L/15kg	Trademark	CMC
Origin	Suzhou, China	HS Code	28121900
Production Capacity	200t/Year		

**Product Description** 

#### Product Spec:

ungsten Hexafluoride WF6 GAS CAS No.: 7783-82-6 EINECS No.: 232-029-1 UN No.: UN2196 Purity: 99.999% Dot Class: 2.3 Appearance: Colorless Grade Standard: Electron Grade, Industrial Grade

#### The COA of Product:

Test items	Unit	s Quality requirement	s Test results
CF4	ppm	<0.5	<0.01
02	ppm	<0.5	<0.01
N2	ppm	<1	0.03
со	ppm	<0.5	<0.02
CO2	ppm	<0.5	<0.01
SiF4	ppm	<0.5	<0.1
SF6	ppm	<0.5	<0.1
HF	ppm	<5	0.19
AI	ppb	≤10	<0.020
As	ppb	≤10	<0.001
В	ppb	≤10	<0.005
Са	ppb	≤5	<0.200
Cd	ppb	≤2	<0.001
Cr	ppb	≤10	<0.020
Fe	ppb	≤10	<0.007
к	ppb	≤5	<0.100
Mn	ppb	≤10	<0.001
Na	ppb	≤5	<0.040
Th	ppb	≤0.1	<0.001
Ті	ppb	≤10	<0.002
Li	ppb	≤10	<0.002
U	ppb	≤0.05	<0.001
Zn	ppb	≤10	<0.005
Si	ppb	≤10	<0.100

Pb	ppb	≤10	< 0.001
Р	ppb	≤2	< 0.300
Mg	ppb	≤10	<0.020
Ni	ppb	≤20	<0.030
Cu	ppb	≤5	< 0.005
Мо	ppb	≤10	<0.001
Total impurities of other metal ppb		≤500	<0.0010





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